

1410 North Hilton, Boise, ID 83706-1255, (208) 373-0502

C.L. "Butch" Otter, Governor Toni Hardesty, Director

NOTICE OF OPPORTUNITY TO REQUEST A PUBLIC COMMENT PERIOD ON A PERMIT APPLICATION AND PROPOSED PERMIT TO CONSTRUCT

In compliance with Section 58.01.01.209, <u>Rules for the Control of Air Pollution in Idaho</u>, notice is hereby given that Hoku Materials, Inc., Pocatello, has applied to the Department of Environmental Quality (DEQ) for a permit to construct, P-2008.0049, to expand the facility's production capacity by 4,000 metric tons of polysilicon per year. The facility, which is a polysilicon manufacturing facility, is located at One Hoku Way, Pocatello, Idaho. A public comment period on the proposed permit will be provided if a written request is submitted on or before April 30, 2008, and directed to Faye Weber, Department of Environmental Quality, 1410 N. Hilton, Boise, Idaho 83706-1255, or <u>faye.weber@deq.idaho.gov</u>, or via <u>www.deq.idaho.gov</u>. Please reference the company name and permit number when sending the request.

You may elect to sign on to DEQ's list serve and receive electronic information automatically at http://www.deq.idaho.gov/Applications/NewsApp/checkCommentCache.cfm

The permit application materials submitted by the facility are available for public review on the DEQ website. All information regarding this project from this notice forward will only be available at www.deq.idaho.gov.

DATED: April 8, 2008.

Faye Weber Air Quality Division